SECTION I LIST OF MANUFACTURERS' QUALIFIED CAPABILITIES FOR EACH TECHNOLOGY				
MANUFACTURER INFORMATION: TTM Technologies, Inc. (Santa Clara) 407 Mathew Street, Santa Clara, CA, 95050 US	PLANT LOCATION: Same Address as Manufacturer	CAGE Code: 65916 Phone: 408-486-3184 Fax: 408-727-1003 EMail:		
CAPABILITIES BY TECHNOLOGY/ASSO	CIATED SPECIFICATION			
Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-17-030872, VQE-18-032677 Rigid Base Material: GM: Glass Base, Woven, Triazine Max. Panel Size: 18.5" x 24.5" Max. Number of Layers: 10 Max. Board Thickness: .079" Min. Hole Size: .023" Drilled Plated-Through Hole Befo Aspect Ratio: 2:1 Through-Hole Min. Conductor Width/Space: .02"/.007" Hole Preparation: Plasma Desmear Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable	and/or Bismaleimide Modified Epoxy Resin,	Flame Resistant		
Finish System: Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Foil Lamination				
CAPABILITIES BY TECHNOLOGY/ASSO	CIATED SPECIFICATION			
Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-03-003888, VQE-10-020500 15-029683, VQE-16-030610, VQE-18-032677), VQE-10-020581, VQE-11-022973, VQE-14	1-028240, VQE-14-028262, VQE-15-029137, VQE-		
Rigid Base Material: GF: Woven E-Glass, Epoxy Resin Max. Panel Size: 21.5" x 24.5" Max. Number of Layers: 28 Max. Board Thickness: .19"	, Flame Resistant			
Min. Hole Size: .0098" Drilled Plated-Through Hole Bef Aspect Ratio: 11:1 Through-Hole Min. Conductor Width/Space: .004"/.004"	ore Plating			
Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate Hole Fill/Via Plug: Conductive, Non-Conductive				
Solder Resist: Liquid Photoimageable Finish System: ENIG, Electrolytic Ni (no Au), HASL, Ho Additional Fab Capabilities: Blind Vias, Foil Lamination				
Controlled Impedance: Differential, Single-Ended CAPABILITIES BY TECHNOLOGY/ASSO	CIATED SPECIFICATION			
Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-03-003888, VQE-10-020500		1-028240, VQE-14-028262, VQE-16-030610, VQE		

18-032677 Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant Max. Panel Size: 18" x 24" Max. Number of Layers: 33 Max. Board Thickness: .19" Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating Aspect Ratio: 9:1 Through-Hole Min. Conductor Width/Space: .004"/.004" Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Liquid Photoimageable Finish System: ENIG, Electrolytic Ni (no Au), HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Foil Lamination, Sequential Lamination Controlled Impedance: Differential, Single-Ended

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MANUFACTURER INFORMATION:	PLANT LOCATION:	CAGE Code: 65916	
TTM Technologies, Inc. (Santa Clara)	Same Address as Manufacturer	Phone: 408-486-3184	
407 Mathew Street, Santa Clara, CA, 95050 US		Fax: 408-727-1003	
		EMail:	
CAPABILITIES BY TECHNOLOGY/ASSOC	LATED SPECIFICATION		
pecification: MIL-PRF-31032/3, MIL-PRF-31032/4			
Qualification Letters: VQE-03-003895, VQE-10-020500, 8-032677, VQE-18-032893	VQE-10-020581, VQE-11-022973, VQE-14	-028240, VQE-14-028262, VQE-16-030610, VQE-	
Rigid Base Material: GF: Woven E-Glass, Epoxy Resin,	Flame Resistant; GI: Glass Base, Woven, F	Polyimide Resin, Heat Resistant	
Flex Base Material: Copper Clad Adhesiveless Polyimid			
/lax. Panel Size: 18.5" x 24.5"			
/lax. Number of Layers: 20			
Max. Board Thickness: .17"			
Ain. Hole Size: .012" Drilled Plated-Through Hole Befor	e Plating		
Aspect Ratio: 9:1 Through-Hole			
/lin. Conductor Width/Space: .004"/.004"			
lole Preparation: Plasma Desmear, Plasma Etchback			
lole Wall Conductive Coating: Electroless Copper			
Copper Plating: Direct Current Plate			
lole Fill/Via Plug: Conductive older Resist: Liquid Photoimageable			
inish System: ENIG, Electrolytic Ni (no Au), HASL, Ho	Oil Reflow of Plated Sn/Pb		
Additional Fab Capabilities: Sequential Lamination			
Controlled Impedance: Differential, Single-Ended			
Flex Usage: Use A (Flex During Installation), Use B (Dy	namic Flex)		
CAPABILITIES BY TECHNOLOGY/ASSOC	IATED SPECIFICATION		
Specification: MIL-PRF-31032/3, MIL-PRF-31032/4			
Qualification Letters: VQE-03-003895, VQE-10-020500,	VQE-10-020581, VQE-11-022973, VQE-14	-028240, VQE-16-030610, VQE-18-032677	
Rigid Base Material: GF: Woven E-Glass, Epoxy Resin,			
lex Base Material: Copper Clad Polyimide with Acrylic	Adhesive		
/ax. Panel Size: 18" x 24"			
lax. Number of Layers: 6			
lax. Board Thickness: .043"			
lin. Hole Size: .0118" Drilled Plated-Through Hole Befo	ore Plating		
spect Ratio: 1:1 Through-Hole			
lin. Conductor Width/Space: .004"/.004"			
lole Preparation: Plasma Desmear, Plasma Etchback			
Hole Wall Conductive Coating: Electroless Copper			
Copper Plating: Direct Current Plate inish System: ENIG, HASL, Hot Oil Reflow of Plated S	n/Ph		
lex Usage: Use A (Flex During Installation), Use B (Dy			
	TATED SPECIFICATION		
Specification: MIL-PRF-31032/1, MIL-PRF-31032/2		020611 VOE 17 020071 VOE 10 020077	
Qualification Letters: VQE-07-013211, VQE-11-022973,			
Composition: M - Mixed based material printed boards, tigid Base Material: GF: Woven E-Glass, Epoxy Resin,			
ligid Base Material: GF: Woven E-Glass, Epoxy Resin, lax. Panel Size: 18" x 24"			
lax. Failer Size: 10 x 24 lax. Number of Layers: 10			
Max. Number of Layers. 10 Max. Board Thickness: 109"			

Max. Board Thickness: .109" Min. Hole Size: .0118" Drilled Plated-Through Hole Before Plating Aspect Ratio: 9:1 Through-Hole Min. Conductor Width/Space: .004"/.004" Hole Preparation: Permanganate Etchback, Plasma Desmear Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

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CAPABILITIES BY TECHNOLOGY/ASSOC	LATED SPECIFICATION			
Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-03-003888, VQE-10-020500, 18-032677		1-028240, VQE-14-028262, VQE-16-030610, VQB		
Rigid Base Material: BI: Aramid Fabric, Nonwoven, Poly	/imide Resin			
Max. Panel Size: 18" x 24"				
Max. Number of Layers: 14				
Max. Board Thickness: .182"				
Min. Hole Size: .012" Drilled Plated-Through Hole Befor	e Plating			
Aspect Ratio: 6.45:1 Through-Hole				
Min. Conductor Width/Space: .004"/.004"				
Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper				
Copper Plating: Direct Current Plate				
Hole Fill/Via Plug: Conductive				
Solder Resist: Liquid Photoimageable				
Finish System: ENIG, HASL, Hot Oil Reflow of Plated S	n/Ph			
CAPABILITIES BY TECHNOLOGY/ASSOC				
Specification: MIL-PRF-31032/1, MIL-PRF-31032/2				
Qualification Letters: VQE-13-026953, VQE-14-028262,	VOE-17-030872 VOE-18-032677			
Rigid Base Material: BF: Aramid Fabric, Nonwoven, Epo				
Max. Panel Size: 18" x 24"				
Max. Number of Layers: 14				
Max. Roard Thickness: .135"				
Min. Hole Size: .0118" Drilled Plated-Through Hole Befo	pre Plating			
Aspect Ratio: 7:1 Through-Hole				
Min. Conductor Width/Space: .0088"/.008"				
Hole Preparation: Plasma Desmear, Plasma Etchback				
Hole Wall Conductive Coating: Electroless Copper				

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Controlled Impedance: Differential